

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	84308	(chuck or stage or support\$4 or position\$4) near5 (wafer or substrate or reticle or mask) and vacuum	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:08
L2	15	1 and (chuck near6 (thermal\$4 or temperature or heat) near6 (isolat\$4 or separat\$5) near6 (base or frame))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:10
L3	21	1 and ((vacuum adj3 (space or gap)) same (chuck) same (frame or base))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:14
L4	464	1 and (chuck near5 (support\$4 or position\$4 or plac\$4) near5 (base or frame))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:17
L5	157	4 and (chuck same (base or frame) same (thermal\$4 or temperature or heat))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:29
L6	25	5 and (((thermal\$4 or temperature or heat) near4 (isolat\$4 or separat\$4)) same (chuck))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:31
L7	1	5 and (phase adj3 transit\$4 adj3 (material or layer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/18 08:33
L8	6	"5685363"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 08:37